## Notes

Entry

Substrate

## A Simple, Convenient, and Efficient Method for the Synthesis of Isocyanates from Urethanes

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There has been significant interest in the manufacture of isocyanates due to their commercial value as precursors to polyurethane elastomers, agrochemicals, adhesives, and reaction injection mouldings (RIM),<sup>1</sup> among other applications. The elimination of alcohol from a urethane<sup>2</sup> constitutes a simple approach to isocyanates. The patent literature is considerable on this subject,<sup>3,4</sup> and the most widely used methods include thermal decomposition reactions with excess powdered boron or bismuth,<sup>3k</sup> and germanium oxide,<sup>3g</sup> effected at high temperatures (greater than 300 °C). Using these stringent conditions, decomposition of the substrate or product can occur, resulting in poor yields of isocyanates. Hence, the development of a mild, efficient procedure for the dealcoholysis of urethanes (eq 1) would provide a superior approach, compared with existing methodologies, in the synthesis of polyurethanes.

$$\operatorname{RNHCO}_{2}\operatorname{Me} \frac{-R'OH}{+R'OH} \operatorname{RNCO}$$
(1)

The isolation of an isocyanate from urethane is complicated by the tendency of formed isocyanate (RNCO) and alcohol ( $R^1OH$ ) to recombine easily as shown in the equilibrium reaction (eq 1). The absence of a reverse addition results in easy isolation of an isocyanate. We wish to report the use of chlorocatecholborane as a reagent for the interception of the components of the

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1			2273	99
2		Н₃С-√О- №СО	2273	100
3		NCO	2274	100°
4			2268	100
5			2265	100
6			2264	98
7			2264	100
8			2266	99
9		≥ NCO	2261	98
10	CH <sub>3</sub> (CH <sub>2</sub> ) <sub>7</sub> NHCO <sub>2</sub> Me	CH <sub>3</sub> (CH <sub>2</sub> )7NCO	2272	96
11	MeO2CHNCH2CH(CH2)3NHCO2Me CH3	OCNCH2CH(CH2)3NCO <sup>d</sup> I CH3	2274	100
12	MeO2CHN CH2NHCO2Me		2271	100 <sup>e</sup>
13	снз         снз           H2CO[CH2CHO]xCH2CHNHCO2Me           HCO[CH2CHO]yCH2CHNHCO2Me           CH3           CH3           CH3           CH3           CH3	СН3 СН3 H2CO[CH2CH0]xCH2CHNCC HCO[CH2CH0]xCH2CHNCC HCO[CH2CH0],CH2CHNCC CH3 CH3		96

	I CH₃ CH₃ H₂CO[CH₂CHO]₂CH₂CHŇHCO₂Me	H2CO[CH2CH0]2CH2CHNCO
	CH <sub>3</sub> CH <sub>3</sub>	Ċн <sub>а</sub> Ċн <sub>а</sub>
14	CH3 CH3 I MeO2CHNCHCH2{OCH2CH]xNHCO2Me	СН3 СН3 I ОСИСНСНДОСН2СНЪИСО <sup>9</sup> 2258 97
	CH <sub>3</sub> CH <sub>3</sub>	сн₃ сн₃ I осиснсн₂(осн₂сн),исо <sup>ћ</sup> 2259 96
15	MeO2CHNCHCH2[OCH2CH]yNHCO2Me	OCNCHCH2OCH2CHJNCO 2259 96

<sup>a</sup> Products were characterized by comparison of spectral data (IR, NMR, MS) and retention times (GC) with authentic materials in most cases. Isocyanates in entries **1-6**, **9**, **10**, and **12** were commercially available. Isocyanates **7**, **8**,<sup>1b</sup> and **11**<sup>4</sup> are known compounds. <sup>b</sup>Yields were characterized by gas chromatography. <sup>c</sup> Isolated yield, 91%. <sup>d</sup> Dytek-A-diisocyanate. <sup>e</sup>Isolated yield 96%. <sup>f</sup> Jeffamine triisocyanate, x + y + z = 83. <sup>g</sup>Jeffamine D-400 diisocyanate, x = 5-6. <sup>h</sup> Jeffamine D-2000 diisocyanate, y = 33 avg.

alcohol from the urethane in the presence of triethylamine as a base (eq 2).

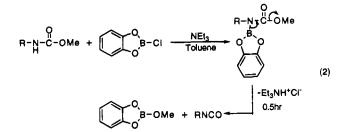
The entire sequence shown in eq 2 occurs rapidly in a one-pot reaction. For instance, refluxing p-tolylurethane with chlorocatecholborane and triethylamine in toluene for 10 min afforded p-tolyl isocyanate in 99% yield. The present transformation is simple and highly selective and

Product <sup>a</sup>

V co Yield<sup>t</sup> (Cm<sup>-1</sup>) (%)

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no side products such as amines were detected. The reaction can also be performed in other nonpolar solvents including pentane or benzene and is highly efficient in the case of other alkylurethanes. For example, ptolylethylurethane is comparable in reactivity with ptolylmethylurethane, affording 100% conversion to p-tolyl isocyanate. The generality of the method has been assessed using a variety of aromatic, aliphatic, and alicyclic urethanes. A series of mono- and diurethanes were subjected to dealcoholysis in the same manner as p-tolylmethylurethane to give the corresponding monoand diisocvanates (Table 1). Industrially valuable diisocyanates were obtained in excellent yields, including toluene-2,4- and 2,6-diisocyanates (TDI), p-phenylenediisocvanate (PPDI), Jeffamine D-400 and D-2000 diisocvanates, and Jeffamine T-5000 triisocvanate (Jeffamine: polymer with a "polypropyleneoxy" backbone).

Triethylamine is required to effect dehydrochlorination from the urethane and chlorocatecholborane. In fact, in the absence of triethylamine, the same reaction affords amines from urethanes instead of isocyanates as the primary product.<sup>6</sup> In conclusion, isocyanates are formed in excellent yield when urethanes are treated with chlorocatecholborane and triethylamine.

## **Experimental Section**

General Procedure for the Preparation of Isocyanates from Urethanes. The urethane (1 mmol) was dissolved in dry toluene (2 mL), triethylamine (1.2 mmol) was added, and the mixture was refluxed for 5 min (N<sub>2</sub> atmosphere). Chlorocatecholborane (1.2 mmol) was added and the mixture was refluxed for another 5 min. After the addition of chlorocatecholborane, an instantaneous reaction was observed and a white cloudy solid material appeared in the reaction flask (due to the formation of  $Et_3NH^+Cl^-$ ). The reaction was monitored by infrared spectroscopy and gas chromatography. The product isocyanate was isolated by vacuum distillation under an N<sub>2</sub> atmosphere or derivatized as ureas using amines, or as other alkylurethanes by reaction with a different alcohol. In case of di- and triurethanes, correspondingly double and triple the amounts of chlorocatecholborane and triethylamine were used.

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